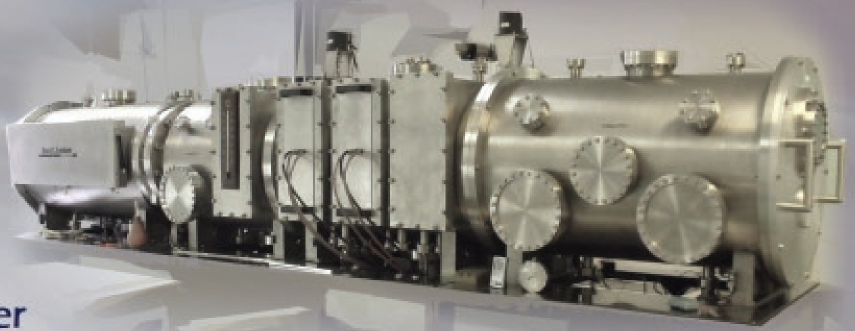
Sputter Facility - Increased Coating Capacity



Small Sputter

- Used for multilayer Research and Development
- 0,2 m^2 useful coating area
- Ni-NiMo/Ti targets for multilayer coating
- Si/Fe targets for polarising multilayer coating

Sputter

- 1m^2 useful coating area
- Designed to operate 4 magnetrons
- Ni-NiMo/Ti targets for multilayer coating
- Automatic, remote controlled

New Sputter

- 1m^2 useful coating area
- Designed to operate 4 magnetrons
- Ni-NiMo/Ti targets for multilayer coating
- Si/Fe targets for polarising multilayer coating
- Automatic, remote controlled

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